

Fig. 1



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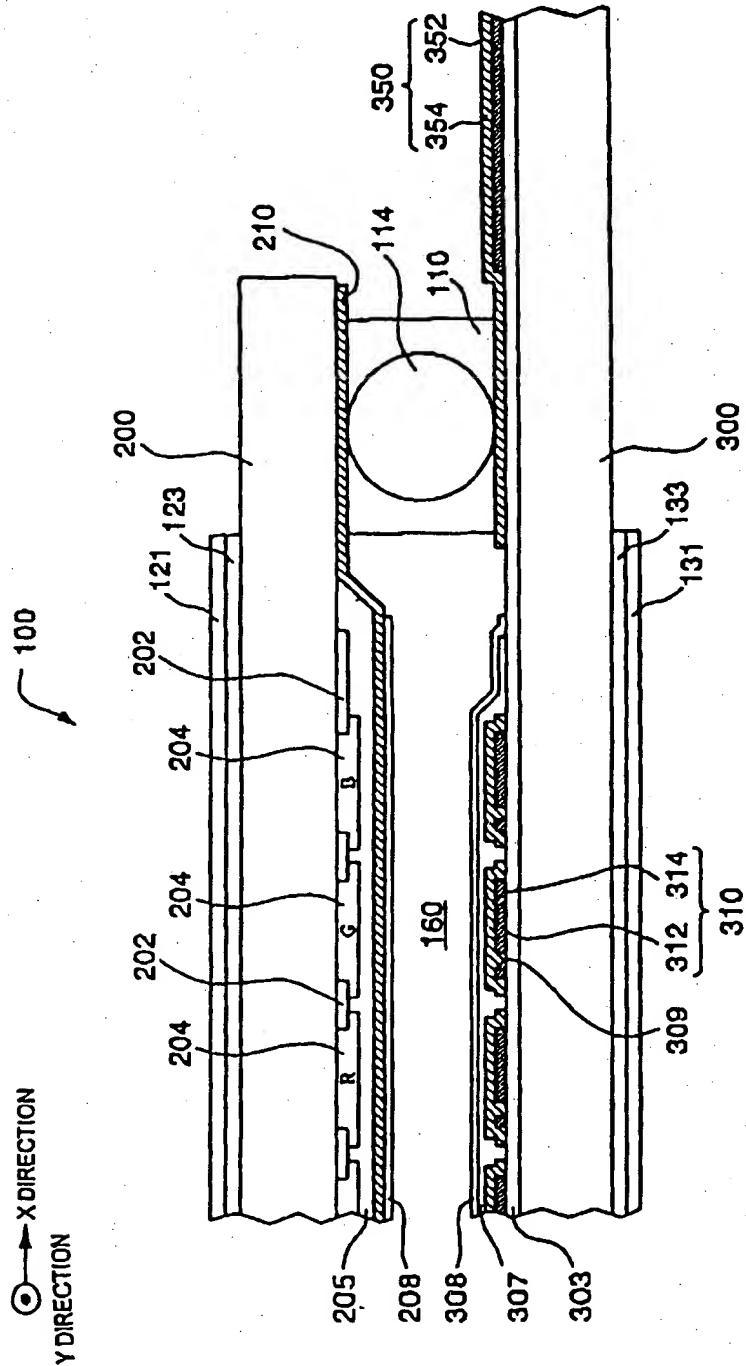


Fig. 2



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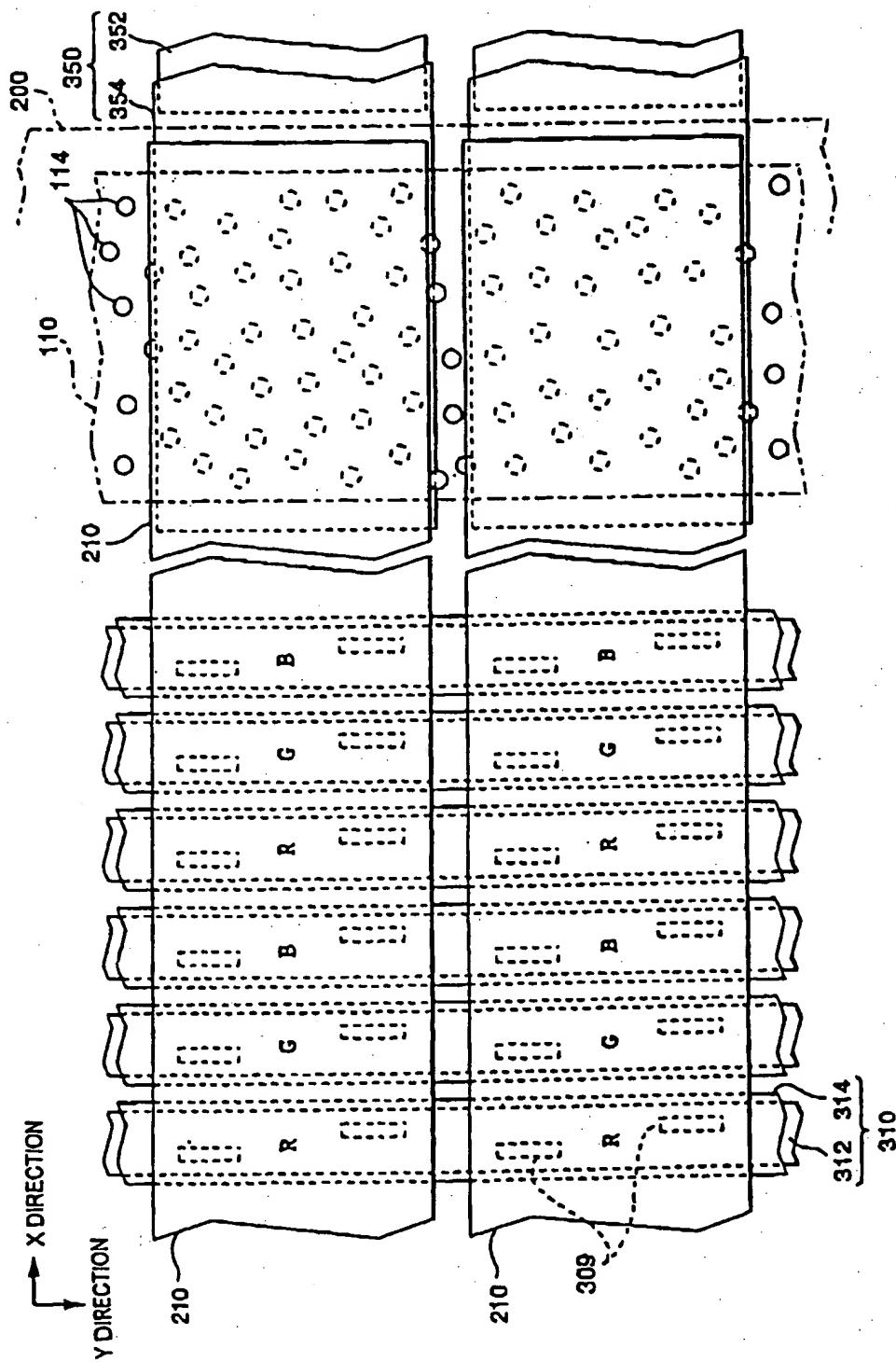


Fig. 3



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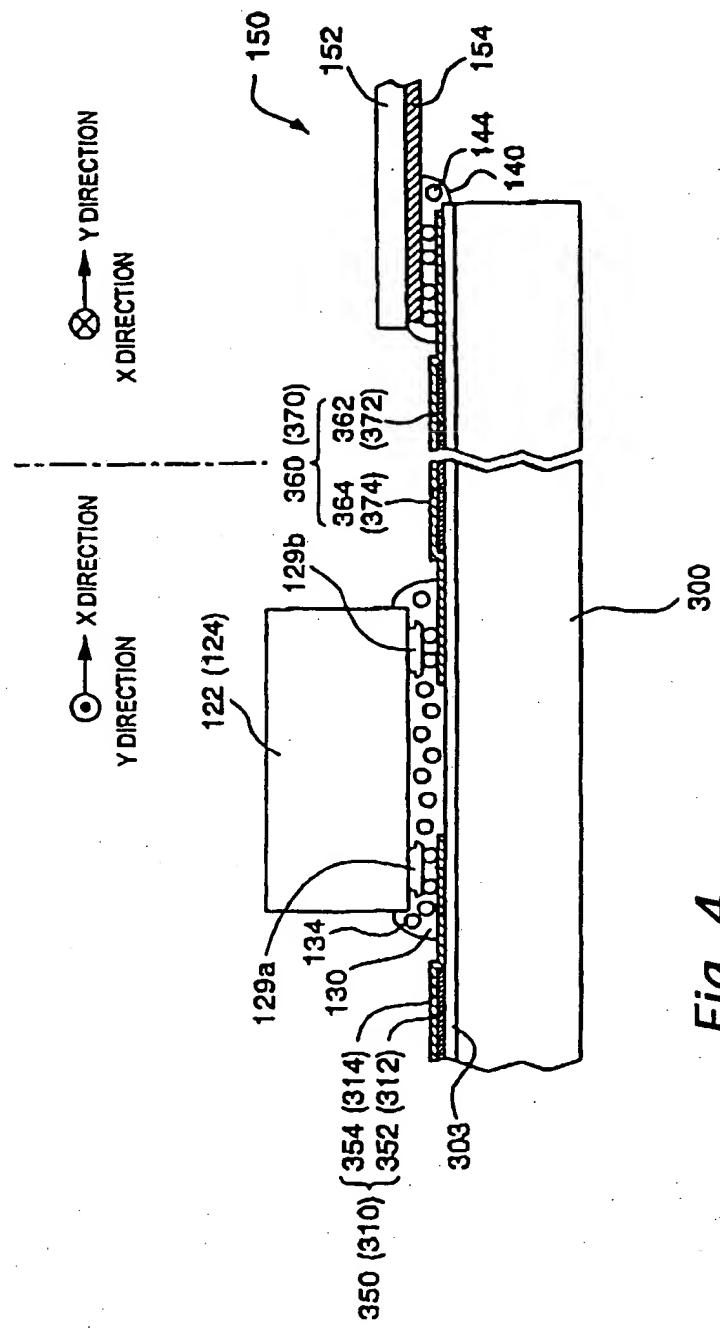


Fig. 4



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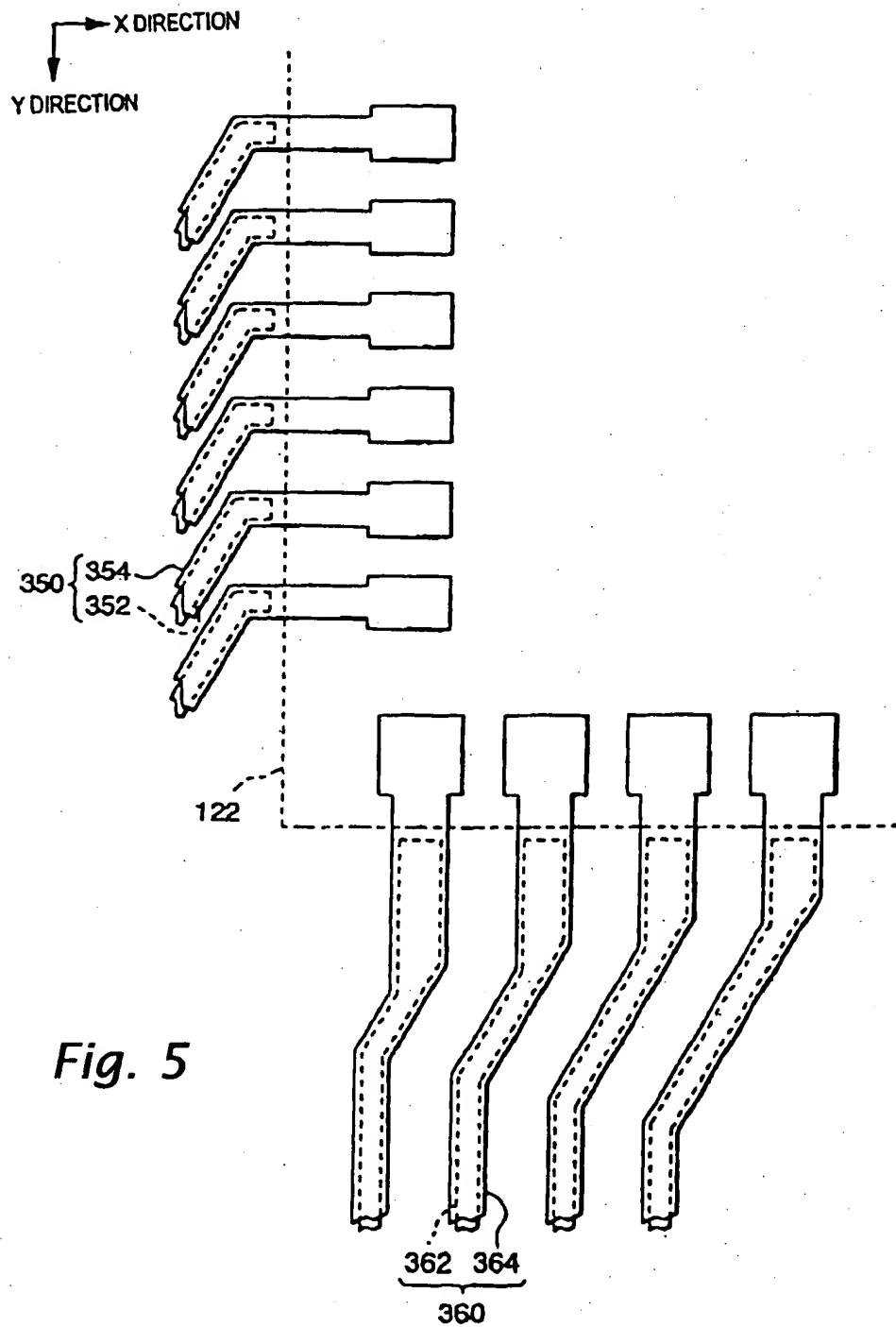


Fig. 5



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Fig. 6a

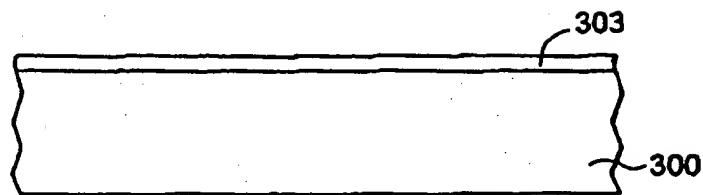


Fig. 6b

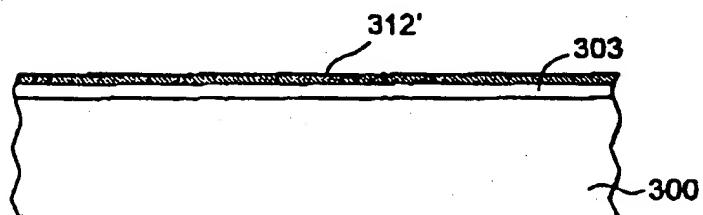


Fig. 6c

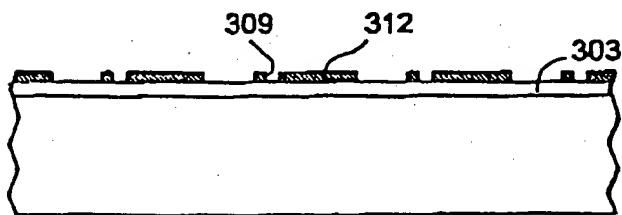


Fig. 6d

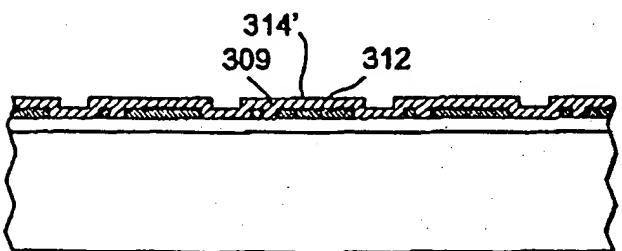
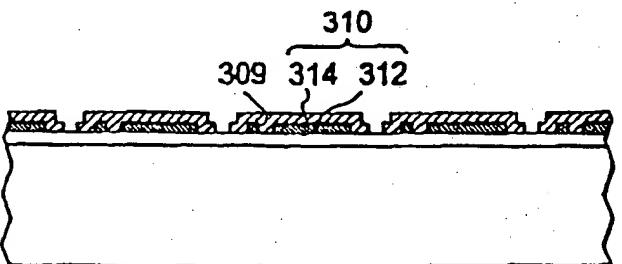
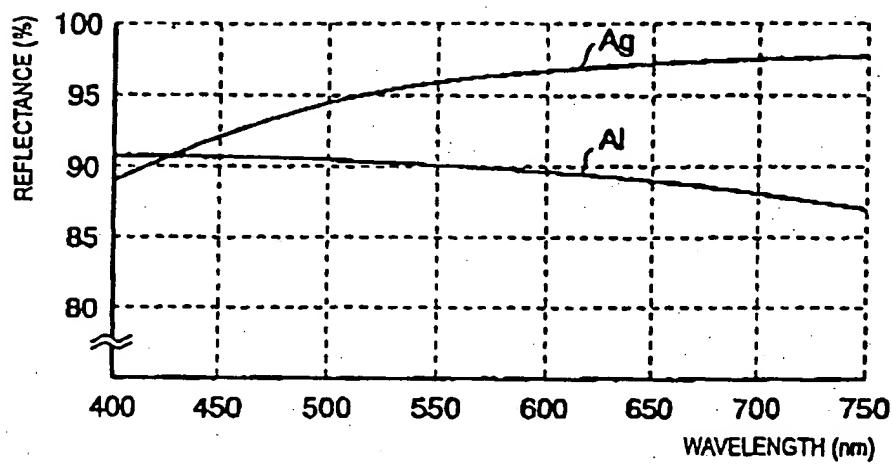


Fig. 6e





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*Fig. 7*

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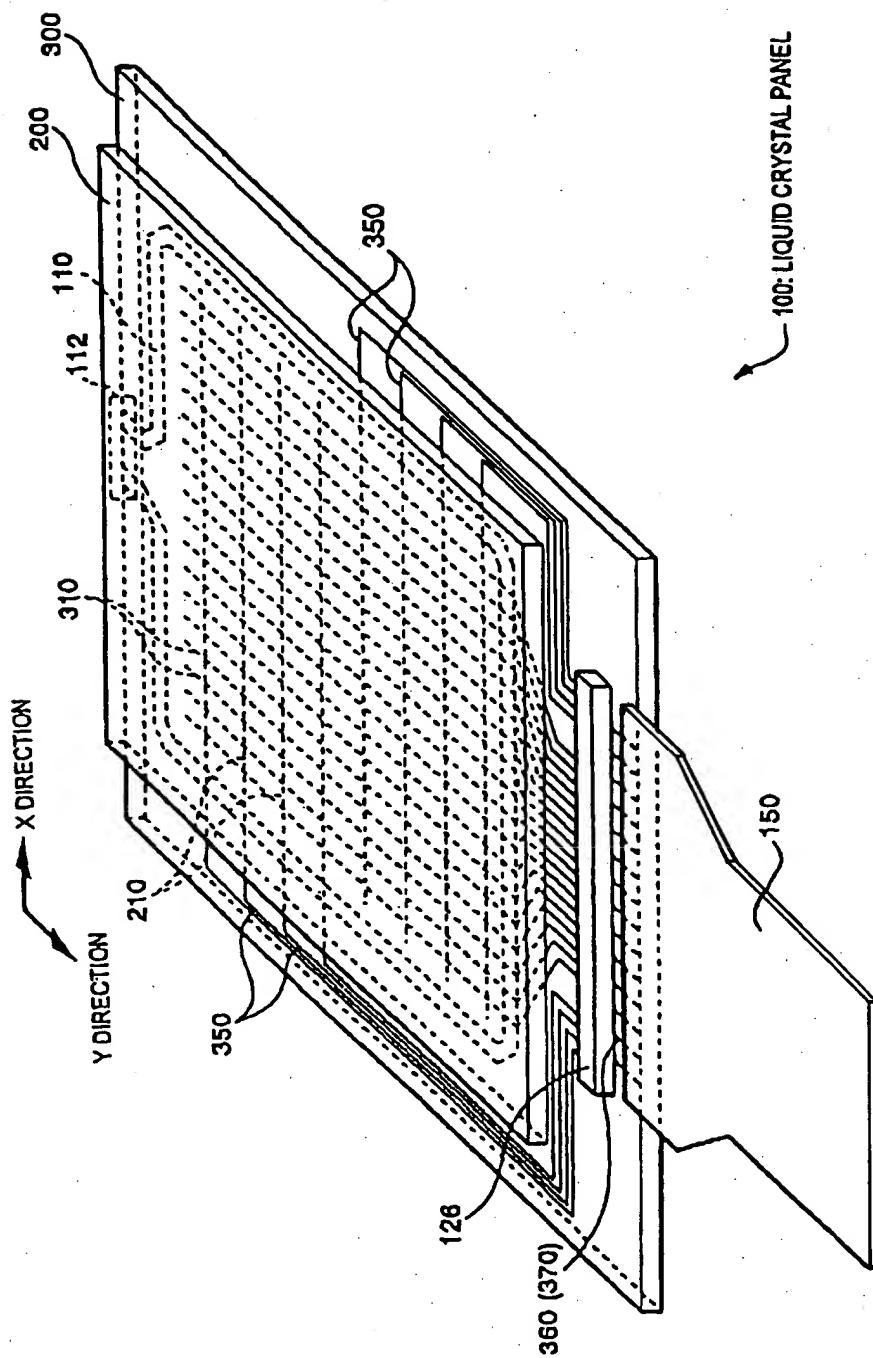


Fig. 8



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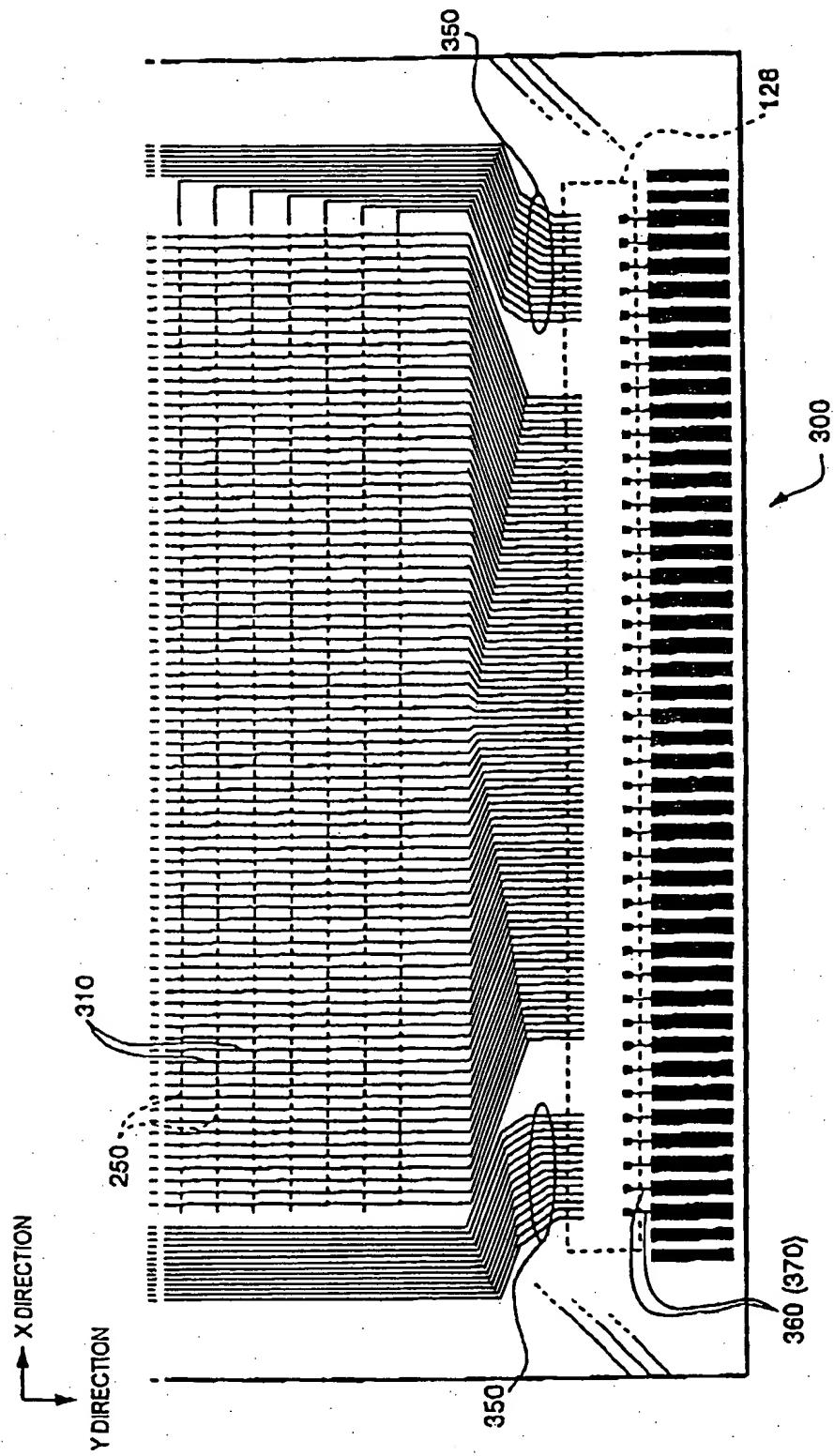


Fig. 9



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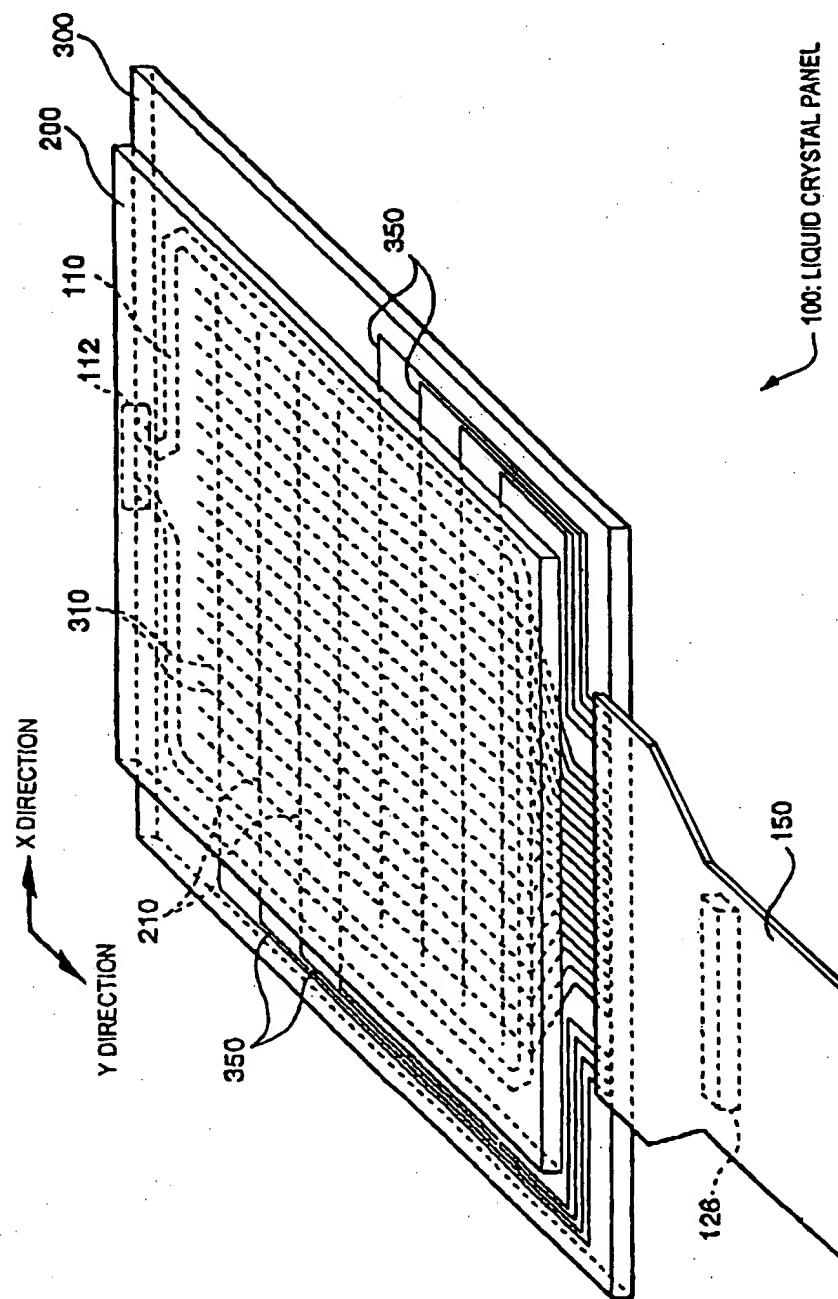
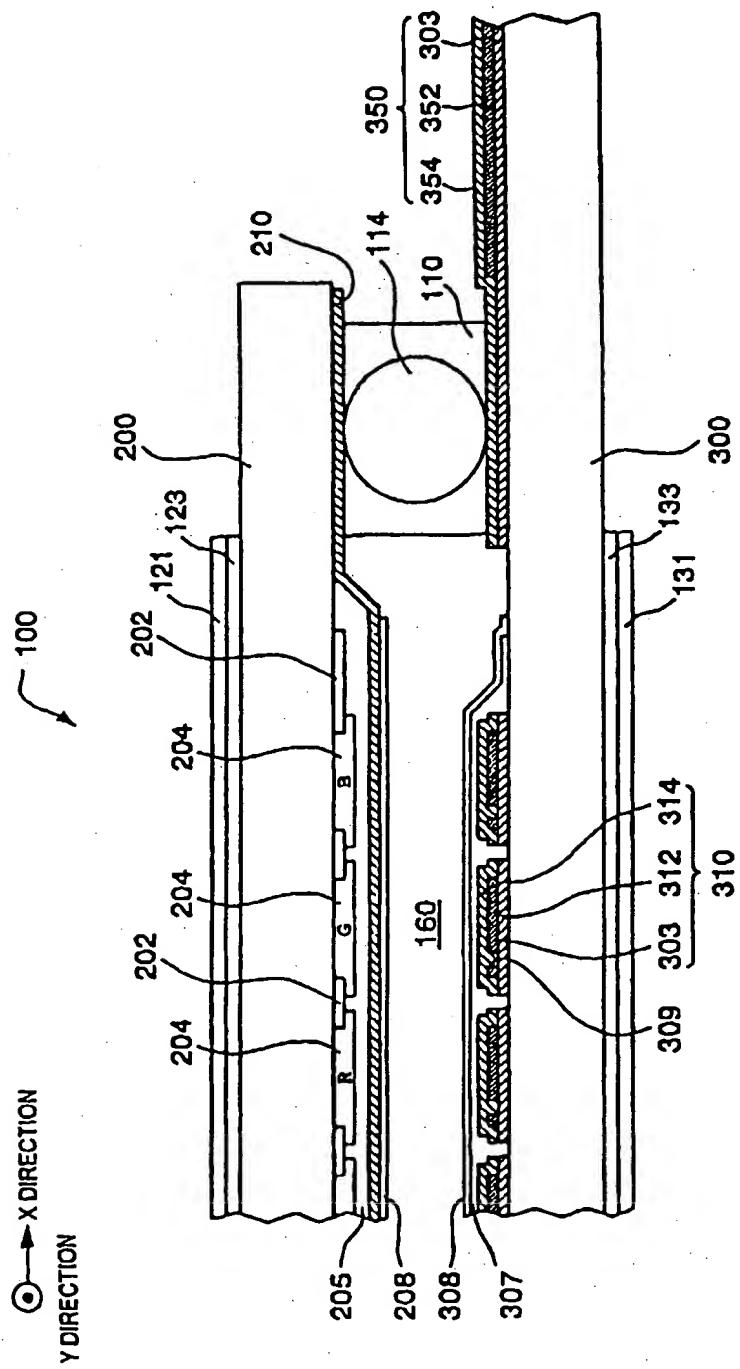


Fig. 10



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**Fig. 11**



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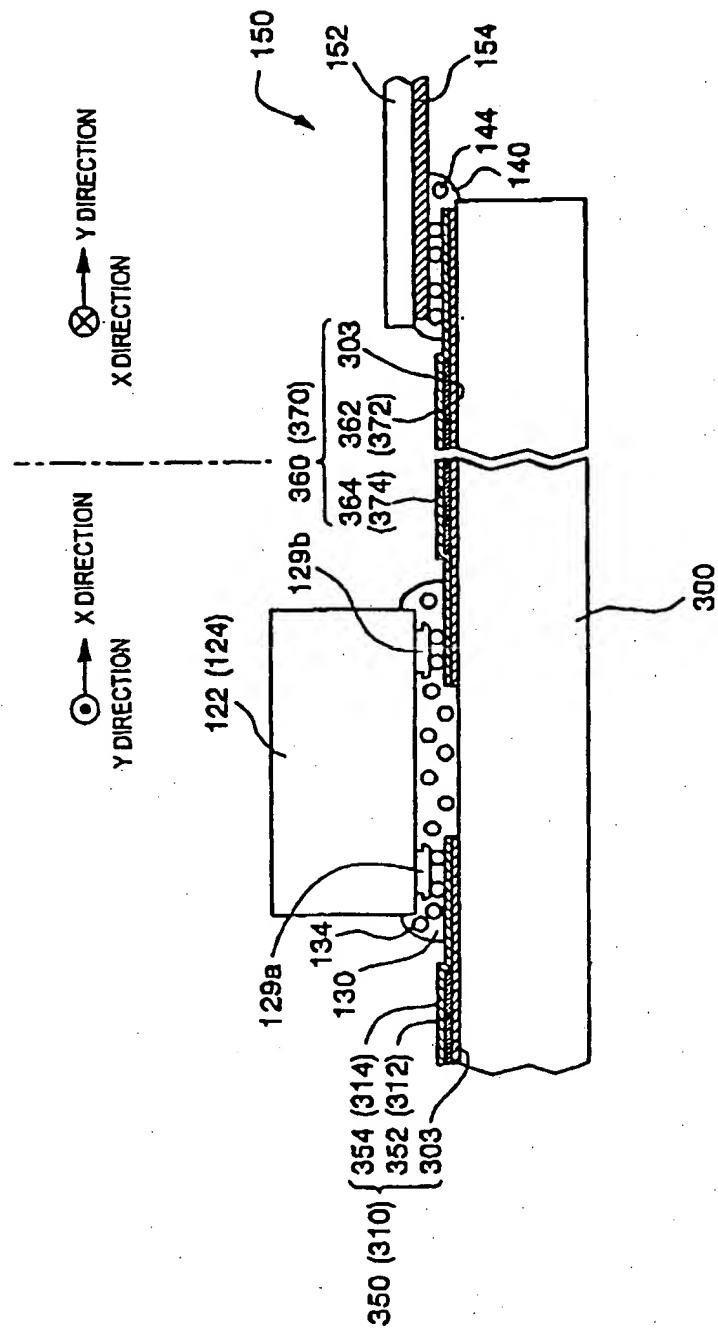


Fig. 12



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Fig. 13a

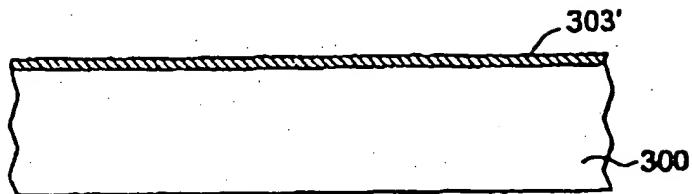


Fig. 13b

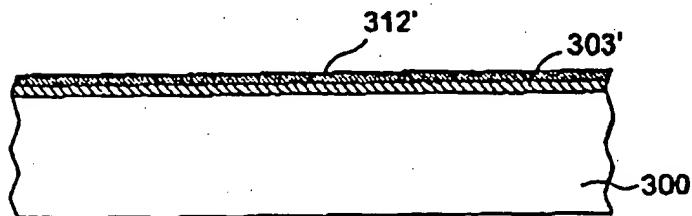


Fig. 13c

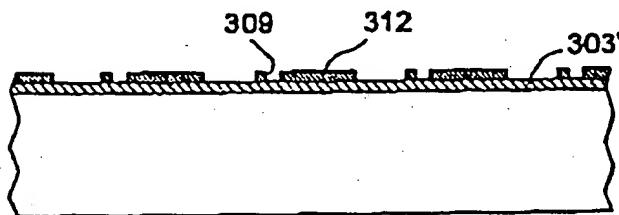


Fig. 13d

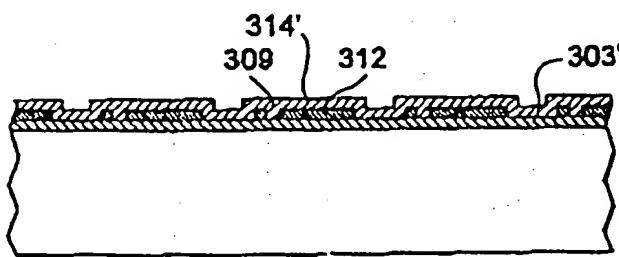
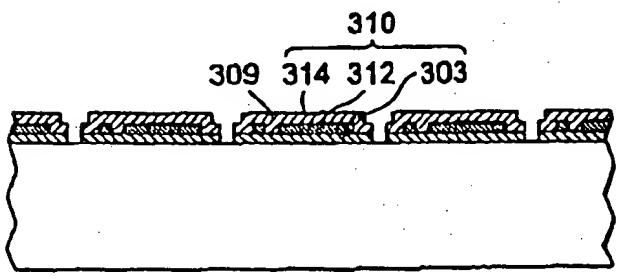
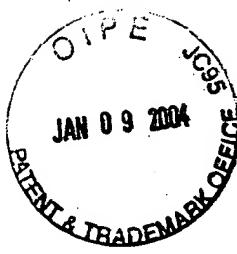


Fig. 13e





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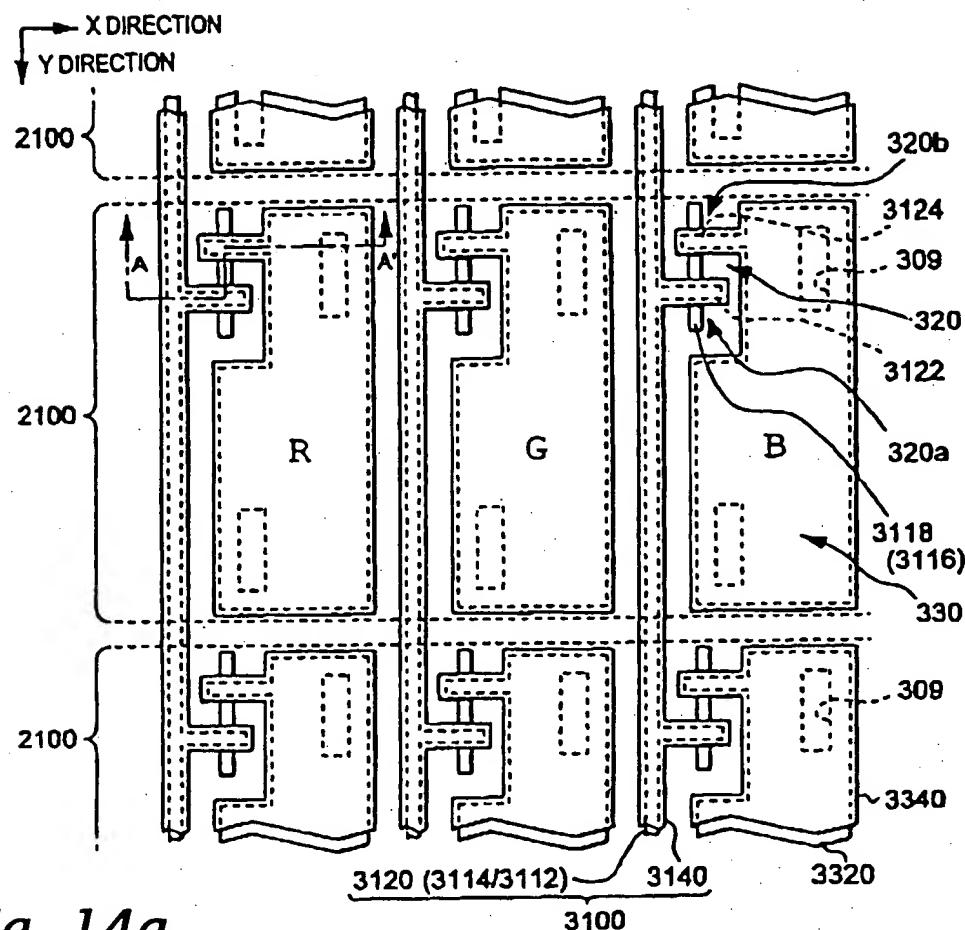


Fig. 14a

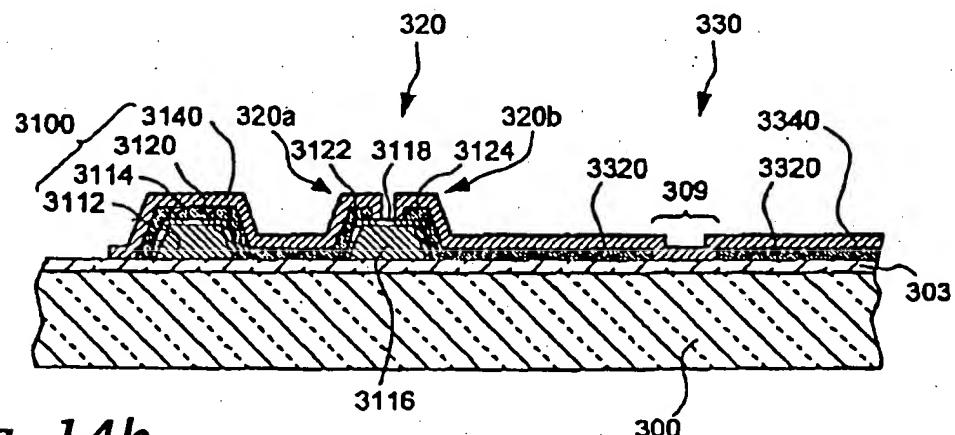
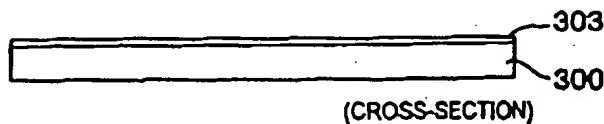


Fig. 14b

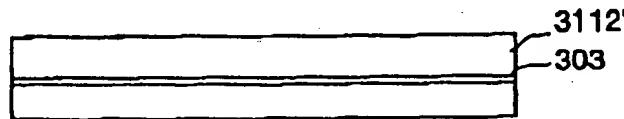


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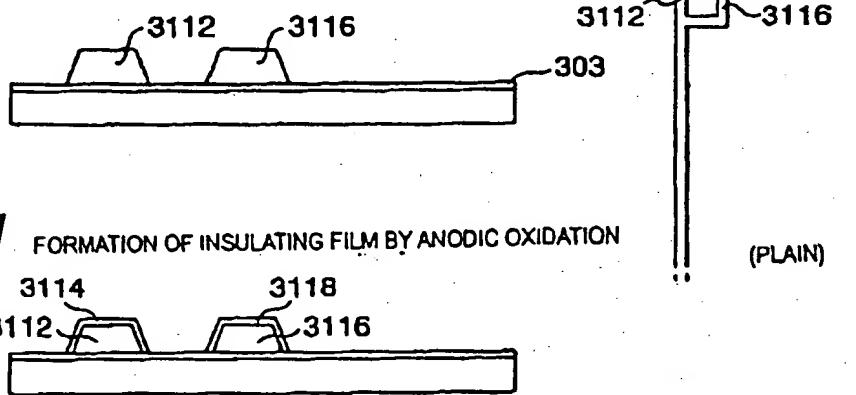
*Fig. 15a* UNDERLYING FILM DEPOSITION



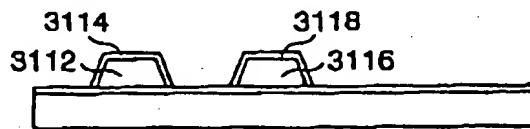
*Fig. 15b*, FIRST METAL FILM DEPOSITION



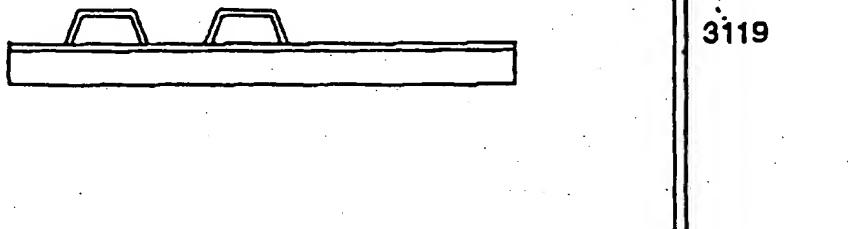
*Fig. 15c* PATTERNING OF FIRST METAL FILM



*Fig. 15d* FORMATION OF INSULATING FILM BY ANODIC OXIDATION



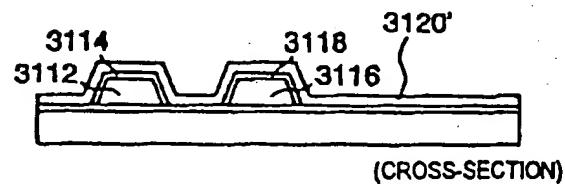
*Fig. 15e* ISOLATION OF ELEMENTS



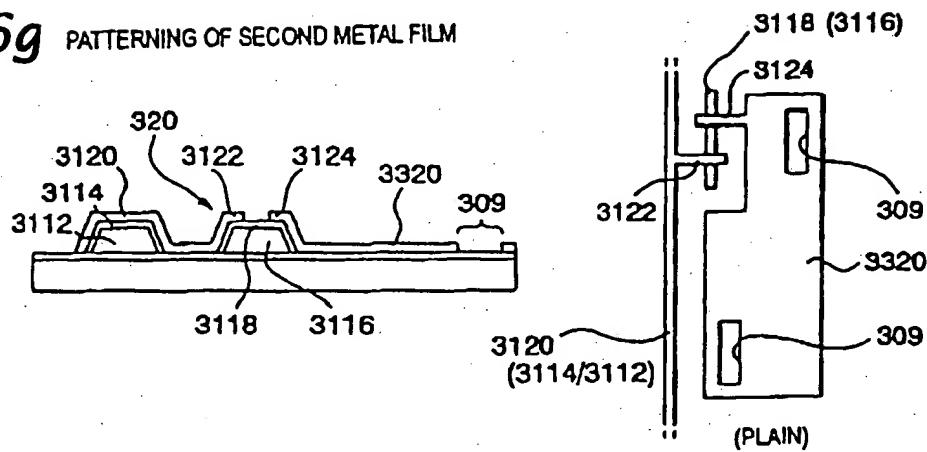


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*Fig. 16f* SECOND METAL FILM (SILVER ALLOY) DEPOSITION



*Fig. 16g* PATTERNING OF SECOND METAL FILM





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Fig. 17h

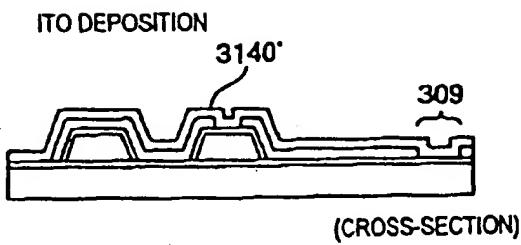
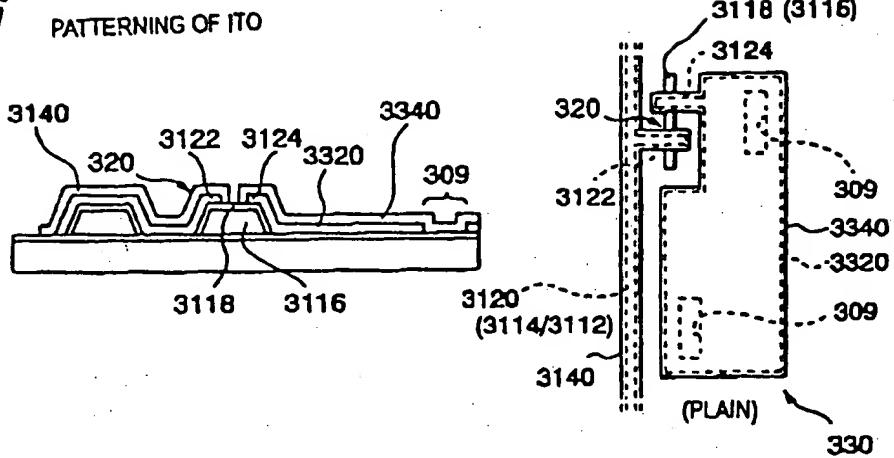


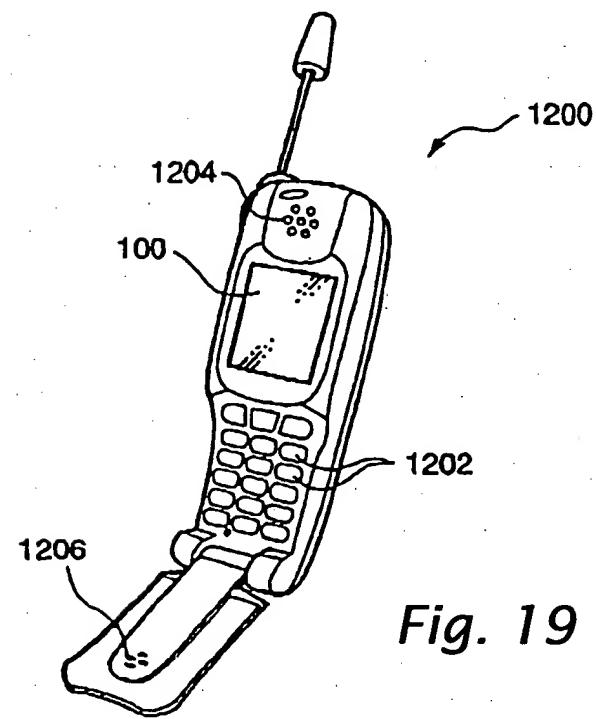
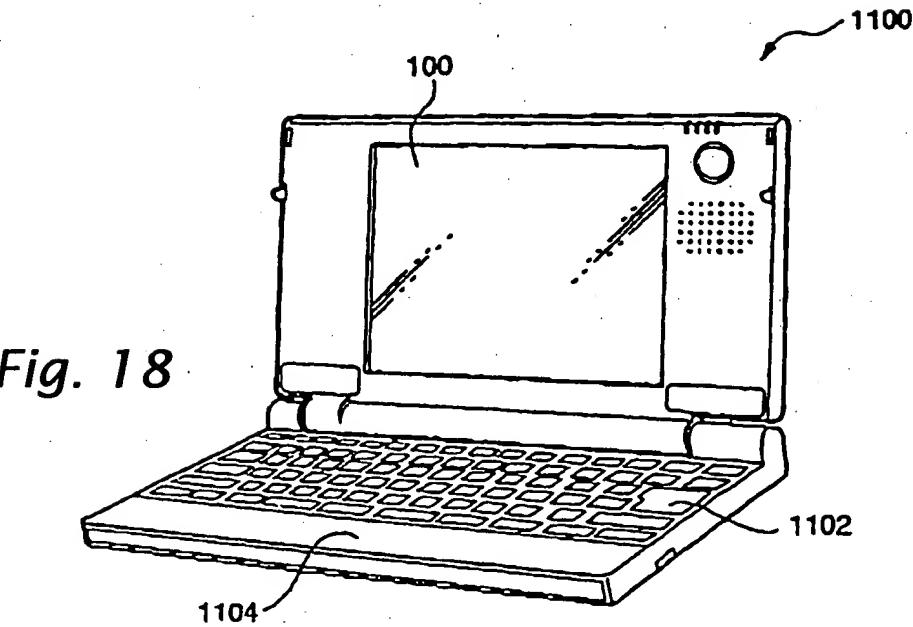
Fig. 17i

PATTERNING OF ITO





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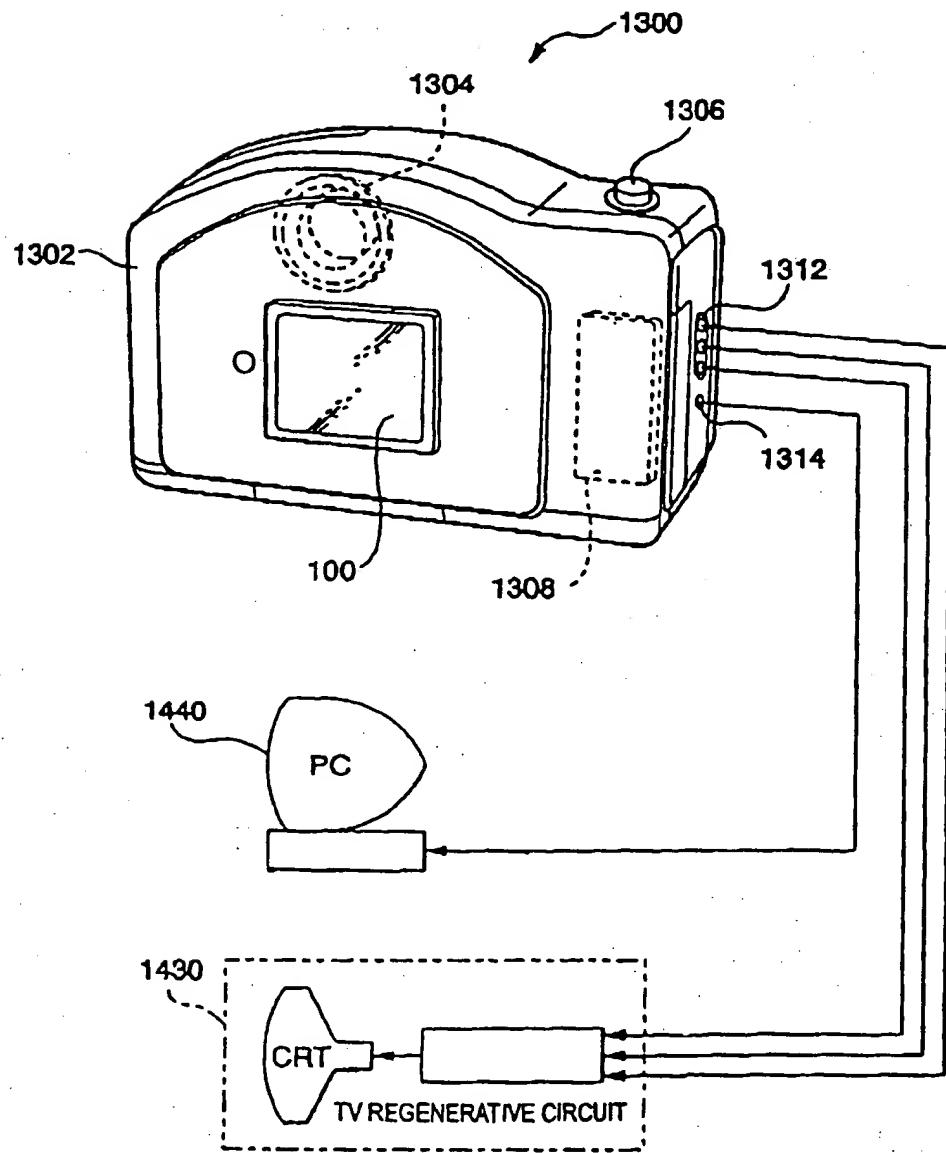


Fig. 20